

MORPHING GRAPHENE FOR ENERGY APPLICATIONS

Valentina Tozzini,

Istituto Nanoscienze del Cnr-Pisa
NEST-SNS Piazza San Silvestro 12
56127 Pisa, Italy



MARIE CURIE ACTIONS



SCAI

SuperComputing Applications and Innovation



GRAPHENE FLAGSHIP



Materials.it, December 12-16 2016, Aci-Castello Catania

NEST

Graphene "real" properties

graphene monolayer



- ✓ Exceptional el mobility
- ✓ Large conductivity
- ✓ Peculiar optical properties
- ✓ Extreme flexibility, strength
- ✓ Large surface to mass ratio
- ✓ 2-Dimensionality



- ✓ Null band gap
- ✓ Null carrier density

Bad for electronics applications

- ✓ Low reactivity
- ✓ Weak interactions
- ✓ No 3-Dimensionality

Bad for storage, sorting and energy applications

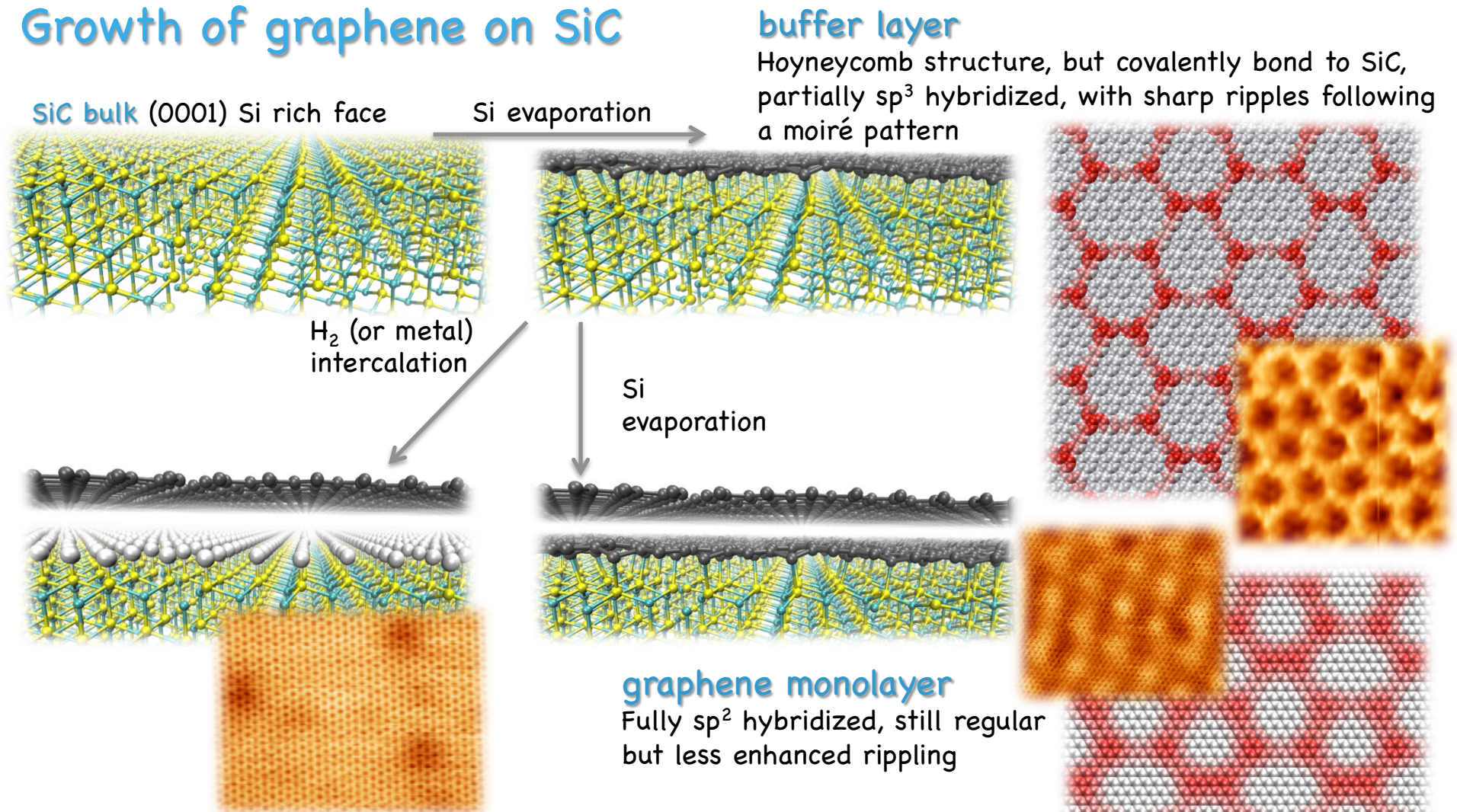
Applications require manipulating graphene

This usually imply disrupting its symmetry. This can be done by

- ✓ Exploit substrates properties
 - Polarization → Doping
 - Corrugation, patterned structure → Specific transport props, control of reactivity
- ✓ Introduction of defects
 - Substitutional → Doping
 - Conformational (curvature) → Control of reactivity and interactions
 - Structural (vacancies) → Control of reactivity and interactions
- ✓ Chemical functionalization
 - ✓ Decoration with atoms (e.g. H) → Band gap opening, storage
 - ✓ Adhesion of chemical anchors → Design of 3D frameworks

Substrate: not just a support for graphene

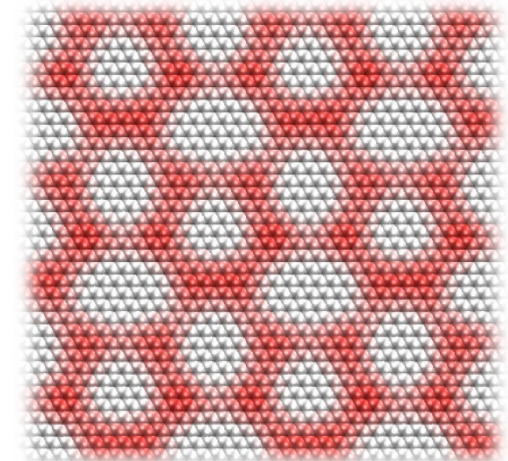
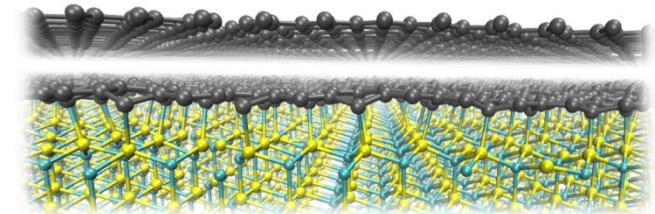
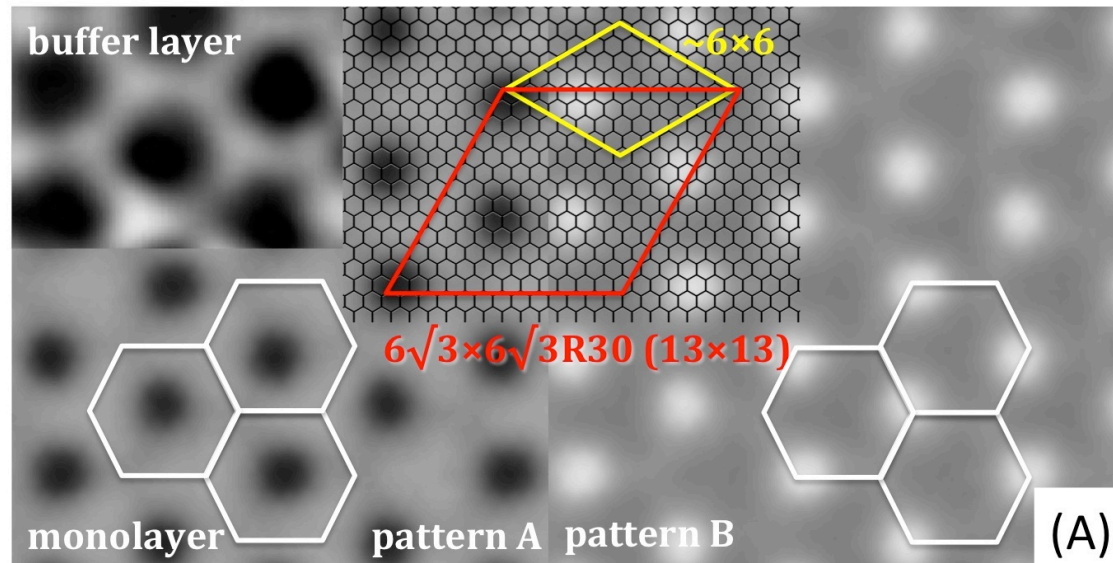
Growth of graphene on SiC



Substrate: not just a support for graphene

Graphene monolayer on SiC: multistable rippling

- ✓ In the literature (both experimental and theoretical) two different curvature pattern are observed depending on environmental conditions: one following the buffer layer, one quite opposite, with protruding hills



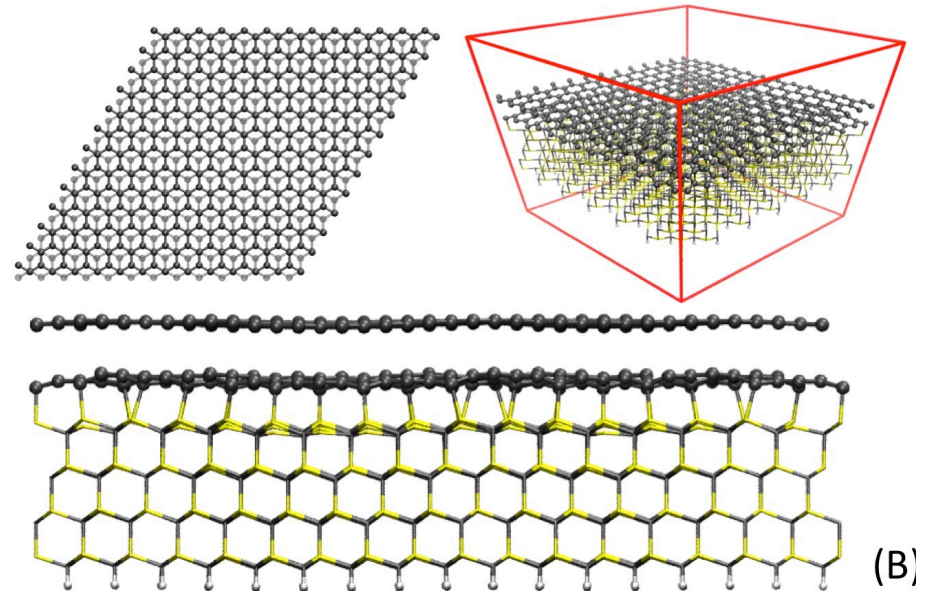
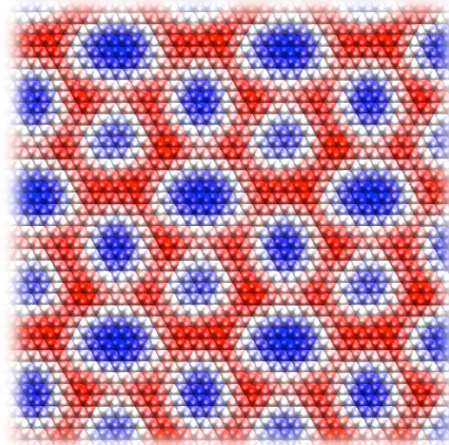
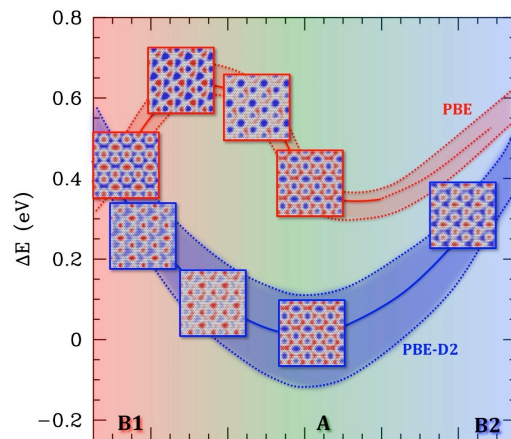
We investigated the relative stability of those patterns and the possibility of switching between them

Substrate: not just a support for graphene

Graphene monolayer on SiC: multistable rippling

Methods

- ✓ DFT calculation on the 13x13 SiC+buffer layer +monolayer (1648 atoms)
- ✓ PW-RRKJUS PP, LDA, PBE, vdW corections
- ✓ Calculations on HCP@CINECA



Results

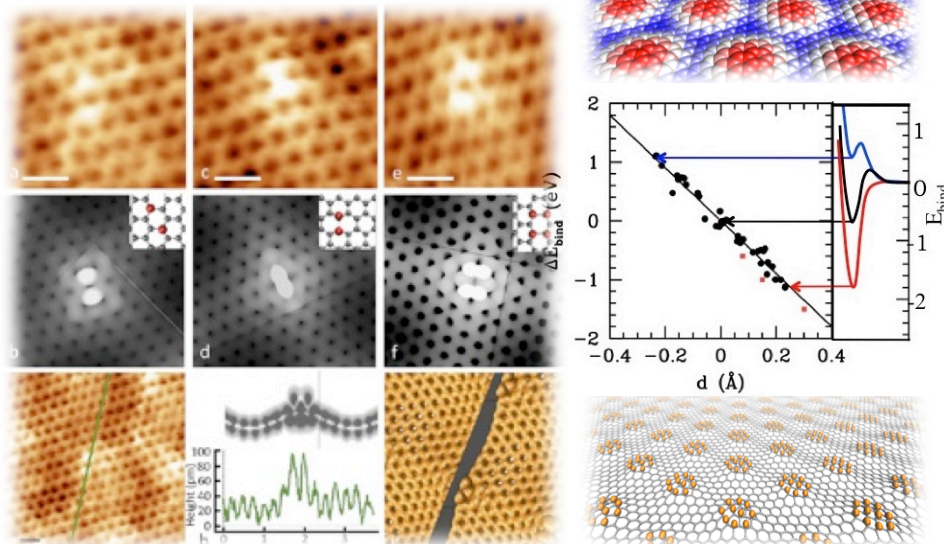
- ✓ Different corrugation pattern can be stabilized by altering the buffer-monolayer interactions

→ The transitions could be driven by changing environmental conditions (e.g. temperature or Electric Fields)

Substrate: not just a support for graphene

Graphene monolayer on SiC: controllable H adhesion

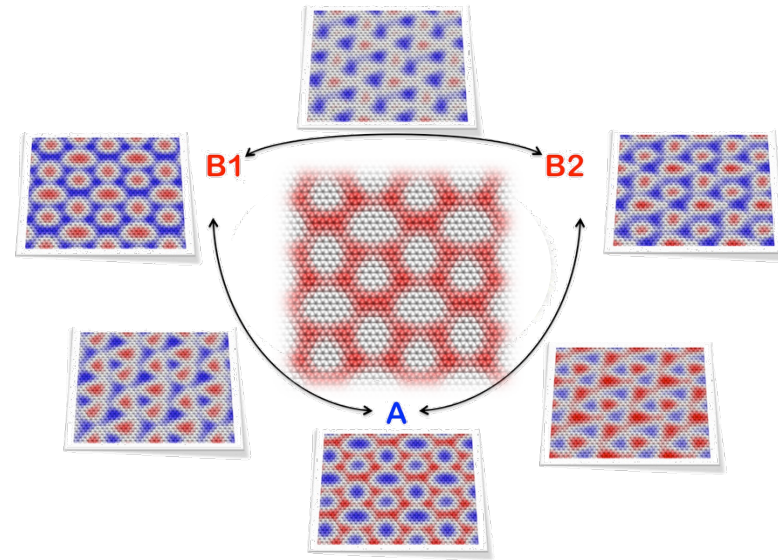
- ✓ Reactivity and stability of ad-atoms are strongly dependent on local curvature: H adhesion is enhanced on hot-spots (convexities)



Nano-Scale Corrugations in Graphene: A Density Functional Theory Study of Structure, Electronic Properties and Hydrogenation A Rossi, S Piccinin, V Pellegrini, S de Gironcoli, and Vtozzini JPCC, 2015

Influence of Graphene Curvature on Hydrogen Adsorption: Toward Hydrogen Storage Devices

Goler, C Coletti, V Tozzini, V Piazza, T Mashoff, F Beltram, V Pellegrini, and S Heun JPC C, 2013

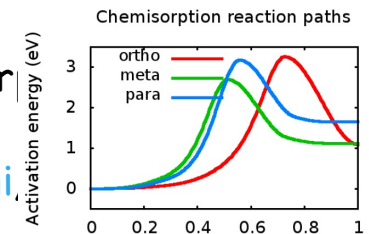


⇒ Decoration with ad-atoms could be driven by the curvature control

✓ **Currently in progress:**

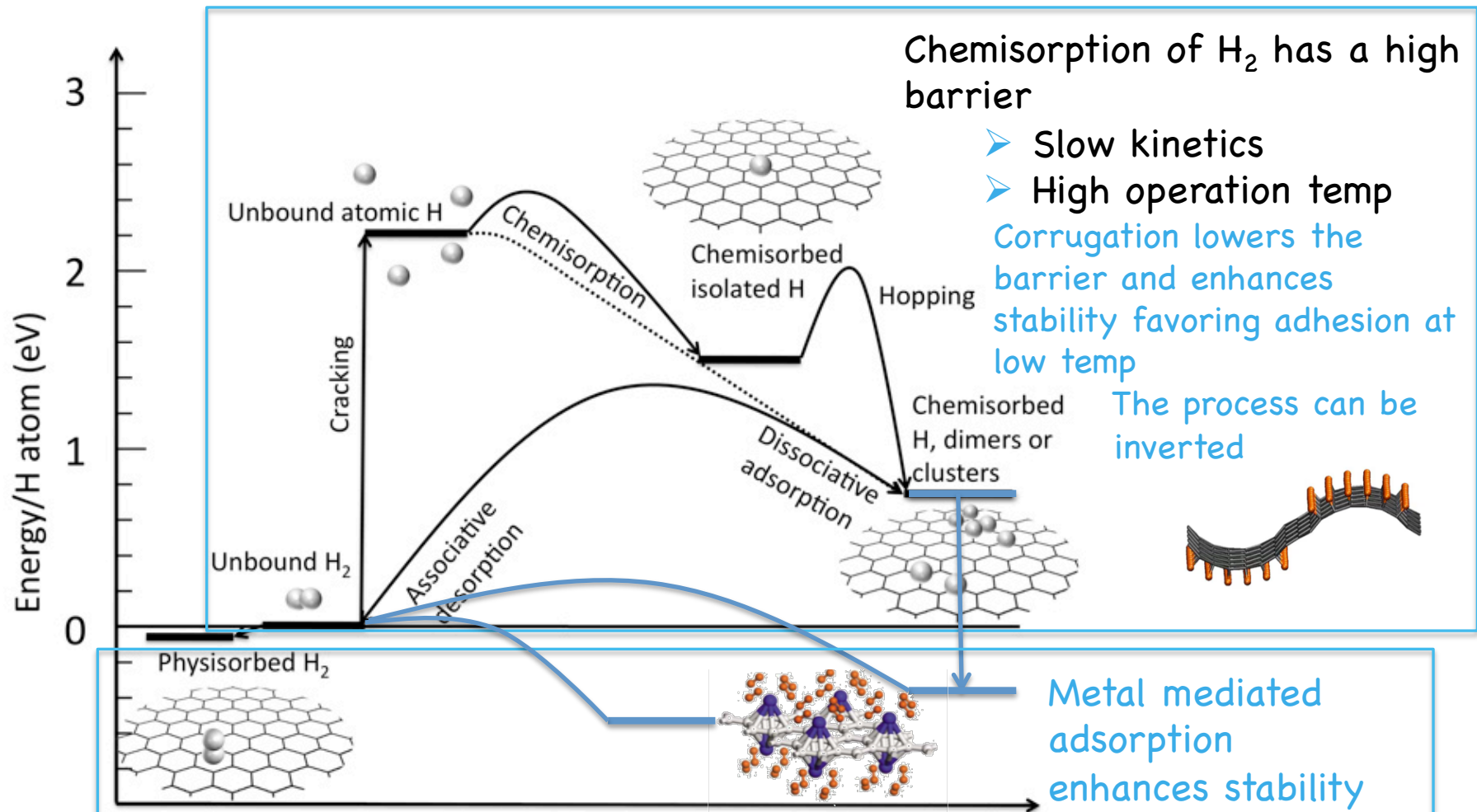
➤ Quantification of chemisorption Barriers as a function of Curvature and EF (K Kakhiani, talk 15th PM1)

➤ Manipulation of curvature by means of electric fields (Tommaso Cavallucci, PhD)



H-storage in graphene

controllable H adhesion

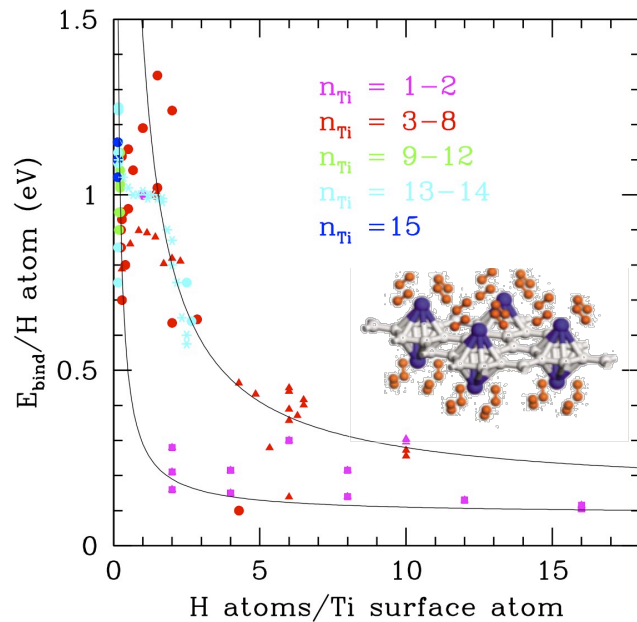


Physisorption of H₂ is weak

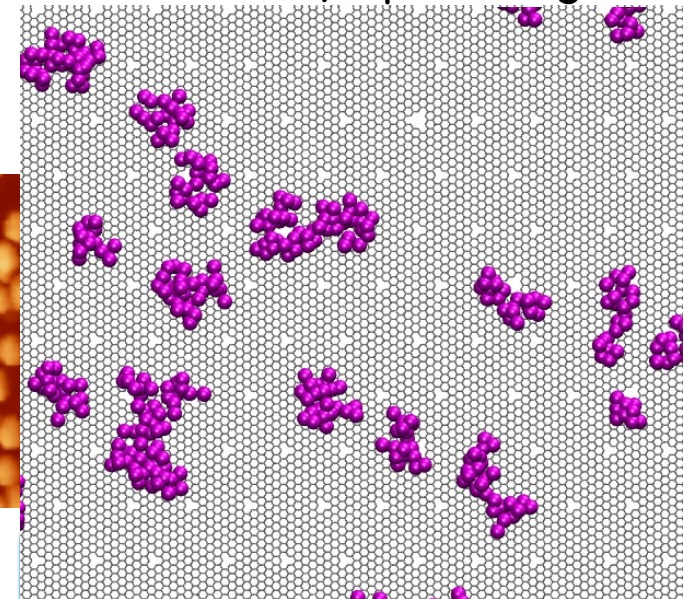
- Limited gravimetric density
- Low temp and/or high press needed

H-storage in graphene

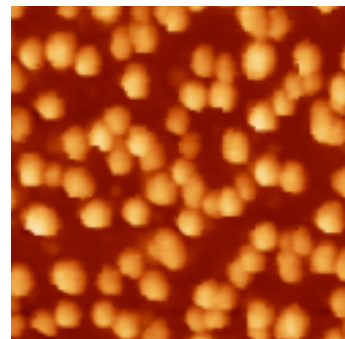
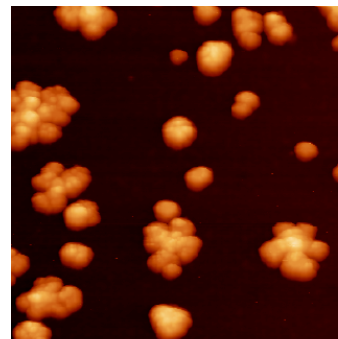
Enhanced H adhesion by multi-modal binding in Ti decorated graphene



- ✓ Ti is capable of binding hydrogen stably at room temp via a multi-modal d-orbital mediated interaction, half way between chemi- and physisorption
Revealing the Multibonding State between Hydrogen and Graphene-Supported Ti Clusters K Takahashi, et al *JPCG*, 2016
- ✓ Ti clusterizes, but optimal H loading (ideally 6.8%, reasonably 2.4%) can be obtained with small clusters
- ✓ distributed clusters can be obtained by sputtering N₂ onto graphene before exposure to Ti



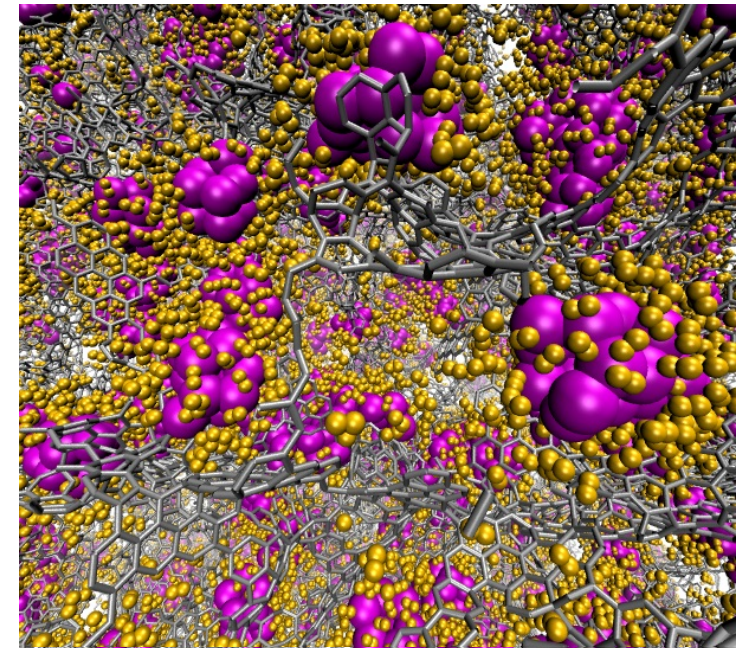
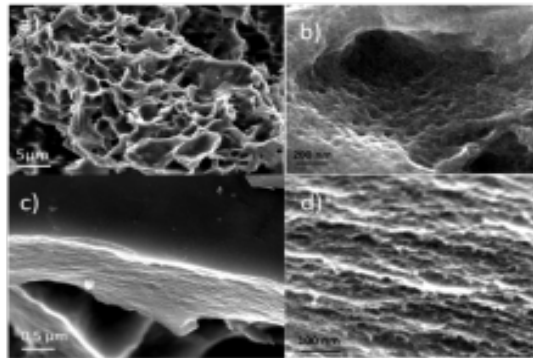
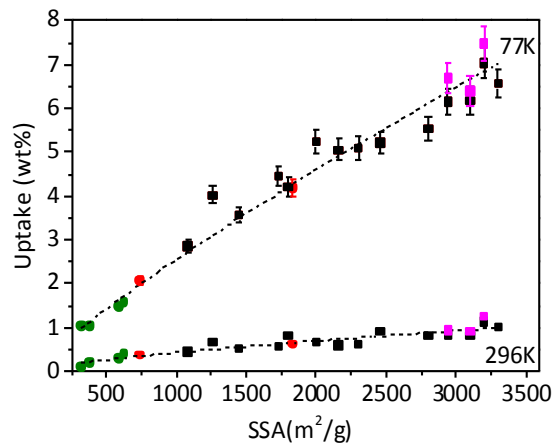
Ti distribution can be optimized for H-storage (work in progress)



H-storage in graphene – Towards 3D systems

H adsorption in 3D graphene-based scaffolds

- ✓ Esfoliation of GO followed by reduction and activation by KOH leads to a number of graphene based materials characterized by different porosity and defectivity



- ✓ The amount of physisorbed H₂ is only dependent on the specific surface area (SSA), which is therefore a physical limit, due to the weakness of vdW interaction
[Hydrogen storage in bulk graphene-related materials](#) A G. Klechikov, et al micr Mes Mater 2015

Ti decoration could overcome this limit. Work in progress (Luca Bellucci)

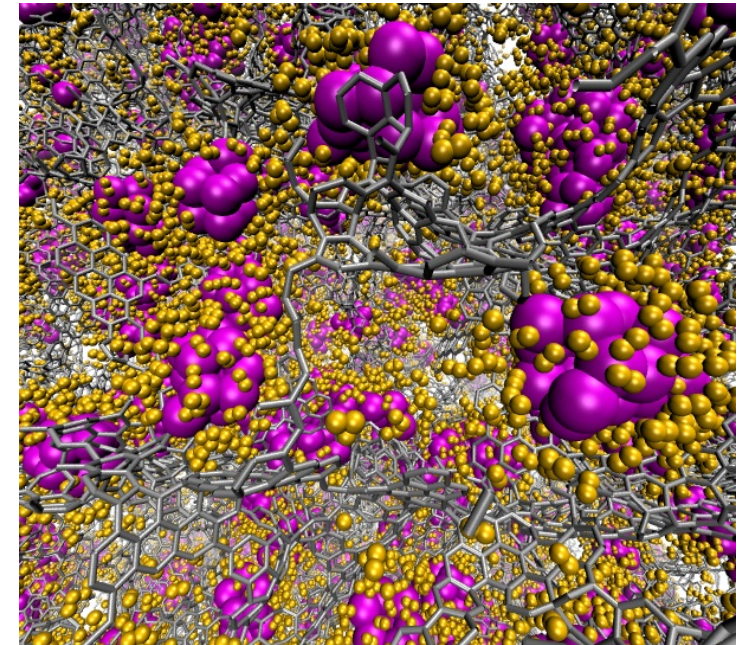
- ✓ Modeling of pristine and Ti decorated graphene scaffolds
- ✓ Simulation of diffusion of H₂ within the system
- ✓ Evaluation of H₂ loading at different P and T
- ✓ Optimization of Ti decoration

H-storage in graphene – Towards 3D systems

H adsorption in 3D graphene-based scaffolds

Methods

- ✓ Empirical FF based simulations – Combination of different FFs – QM/MM approaches
- ✓ Optimization for an algorithm to generate scaffolds with given porosity and density
- ✓ Evaluation of SSA by means of surface generation algorithms
- ✓ Empirical valuation of H₂ adsorption isotherms (BET)
- ✓ Evaluation of diffusion of H₂ diffusion in the structure by simulations



Preliminary results are encouraging:

- Ti stably binds to structural defects
- H₂ molecules stably bind and can lead to high GD at RT

Problems to solve:

- how to tune the size of Ti clusters and their density into the 3D str

Ti decoration could overcome this limit. Work in progress (Luca Bellucci)

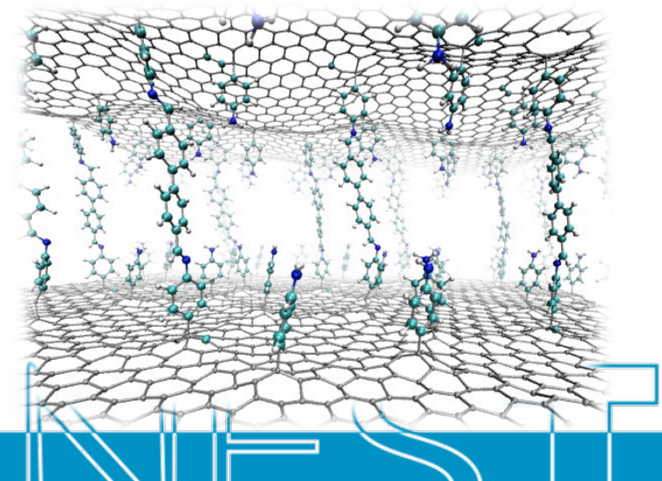
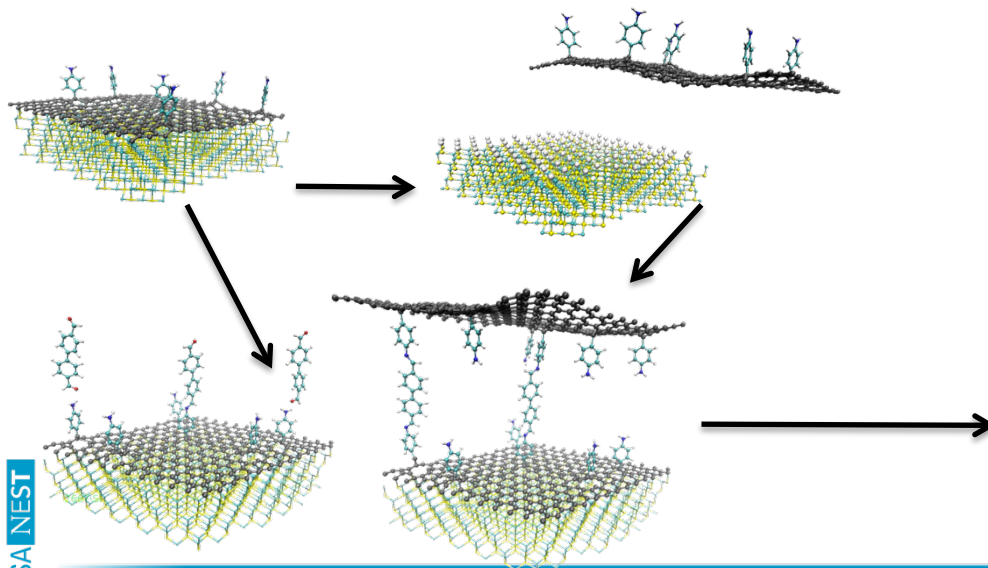
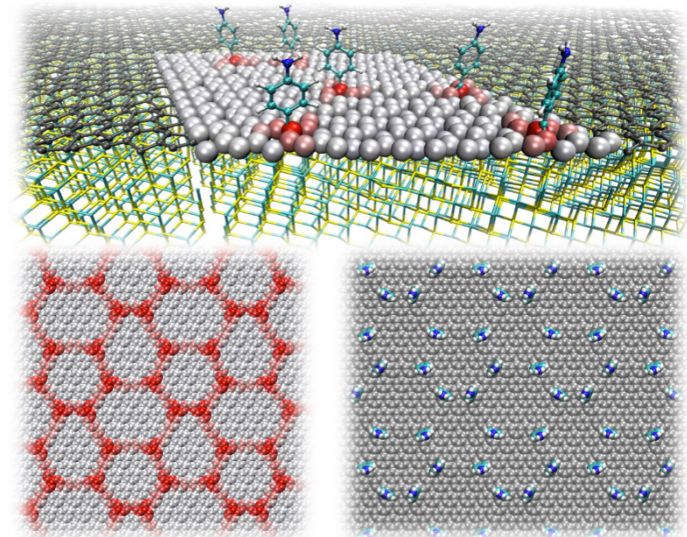
- ✓ Modeling of pristine and Ti decorated graphene scaffolds
- ✓ Simulation of diffusion of H₂ within the system
- ✓ Evaluation of H₂ loading at different P and T
- ✓ Optimization of Ti decoration

H-storage in graphene – Towards 3D systems

Design of 3D graphene-based pillared frameworks: How to exploit the properties of epitaxial graphene

Limit of graphene scaffolds: very difficult to manipulate or design structure

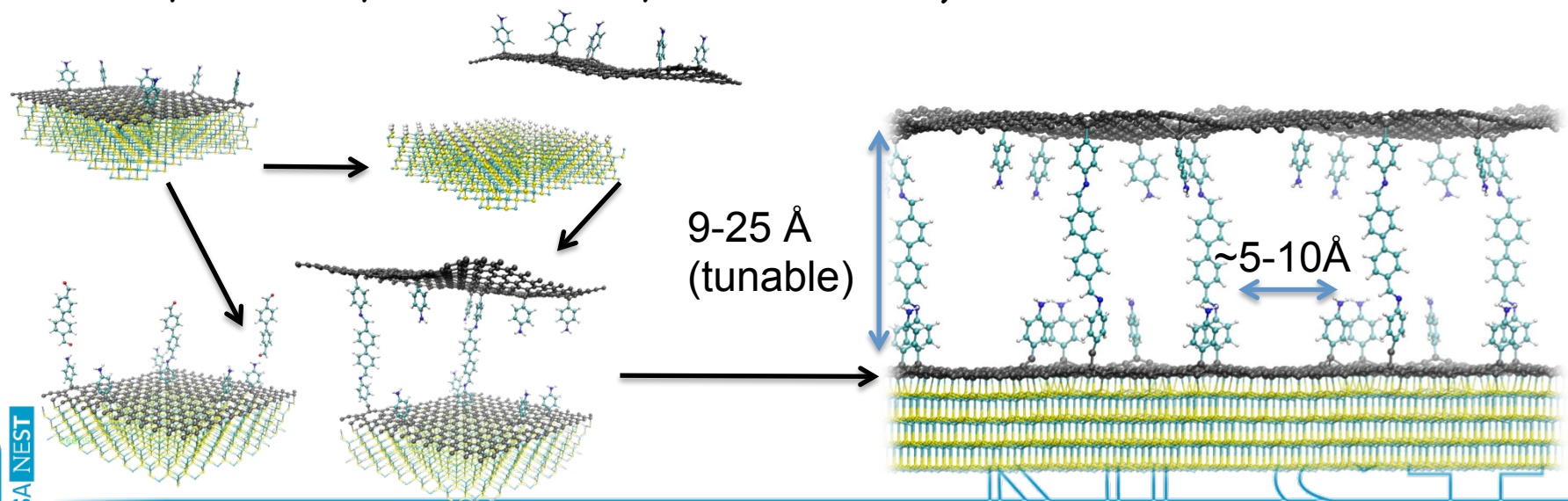
- ✓ Graphene on SiC corrugation creates hot spots of reactivity which could be exploited to drive the chemical adhesion of anchor molecules
- ✓ The anchors will be regularly spaced
- ✓ Pillar molecules can be added and will be regularly spaced as well
- ✓ The formation of stacked structures will be favored



H-storage in graphene – Towards 3D systems

Design of 3D graphene-based pillared frameworks: How to exploit the properties of epitaxial graphene

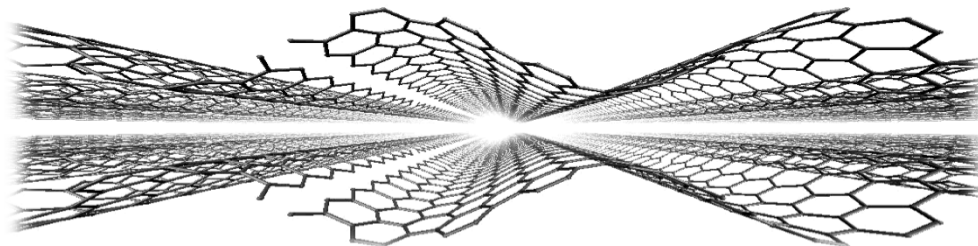
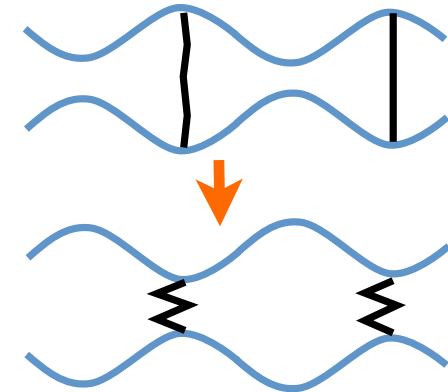
- ✓ Advantages with respect to scaffolds: structural properties can be tuned!
Pillars length, rigidity and shape determine the average density, mechanical properties and porosity of the framework
- ✓ Where are we
 - Modeling: preliminary structures are available, and their properties under evaluation; simulation of reactivity of buffer and moolayer is in progress
Luca Bellucci (Cnr-NANO Pisa)
 - Experiment: Anchor adhesion is being tried (Cnr-NANO and iit-CNI Pisa S Heun, C Coletti, and iit Genoa, Silvia Giordani)



H-storage in graphene – Towards 3D systems

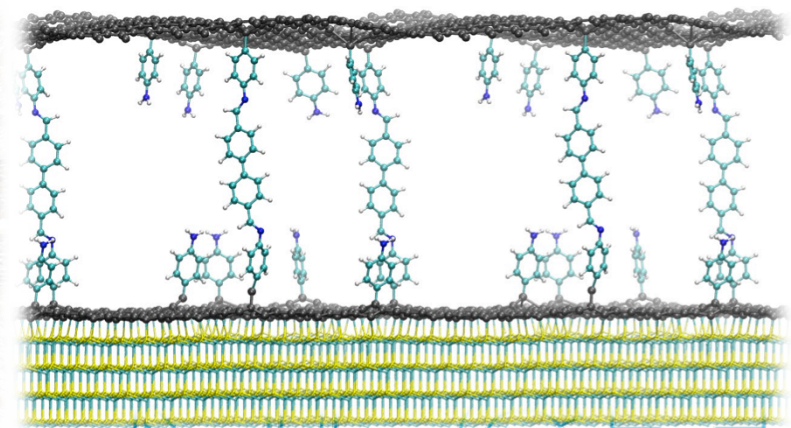
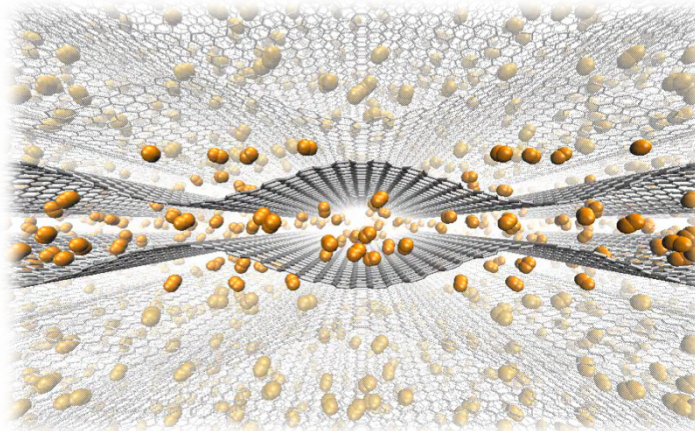
Design of 3D graphene-based pillared frameworks Perspectives

- ✓ The system could be enriched with special properties, e.g. by using optically active pillars: the network could be squeezed or expanded by means of an optical pulse
- ✓ Depending on the distribution of pillars and frequency of pulse, this could generate and sustain flexural phonons...



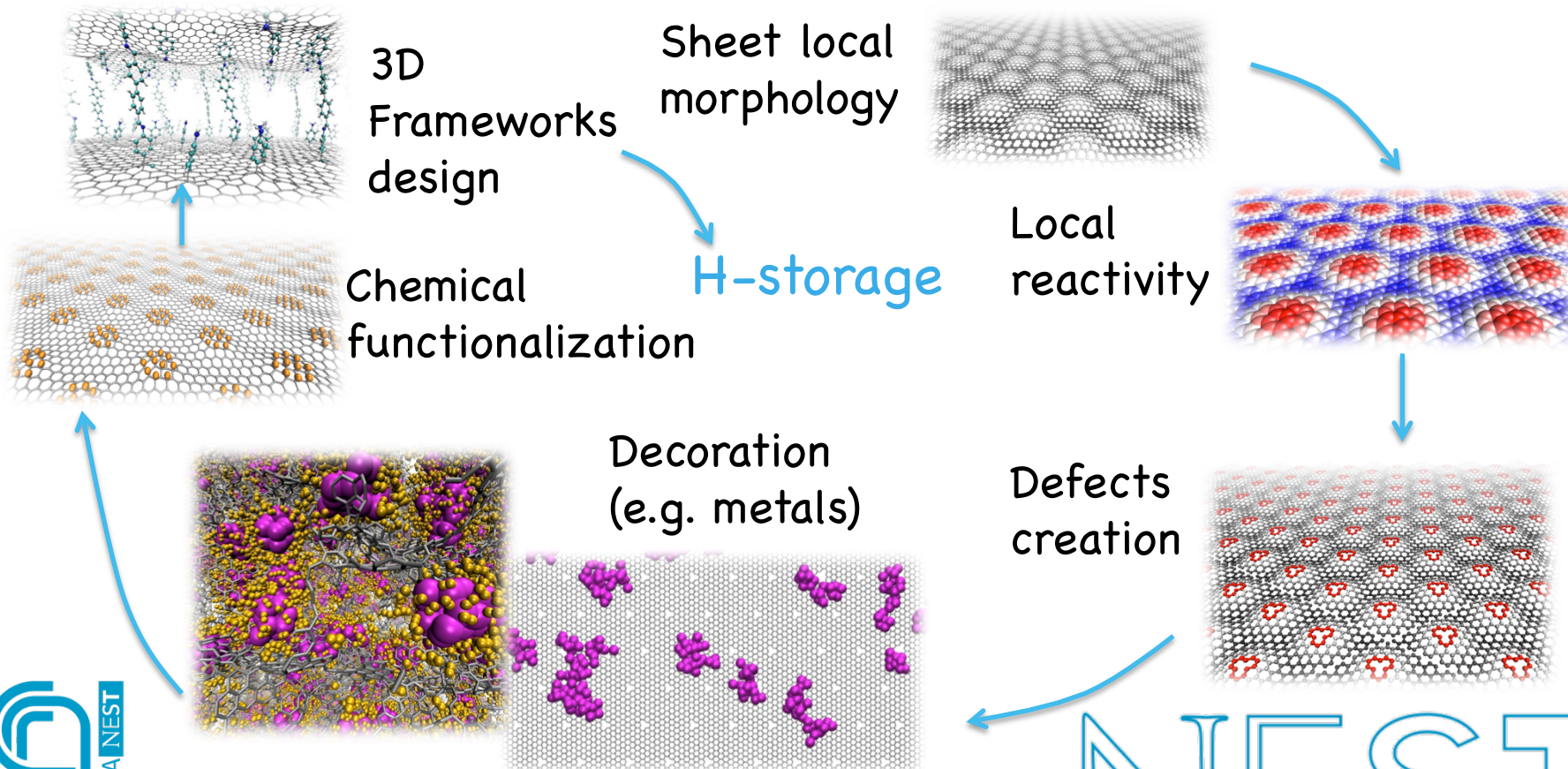
V D Camiola et al 2015 2D Mater. 2 014009

... which could be used to move or pump gases through the structure



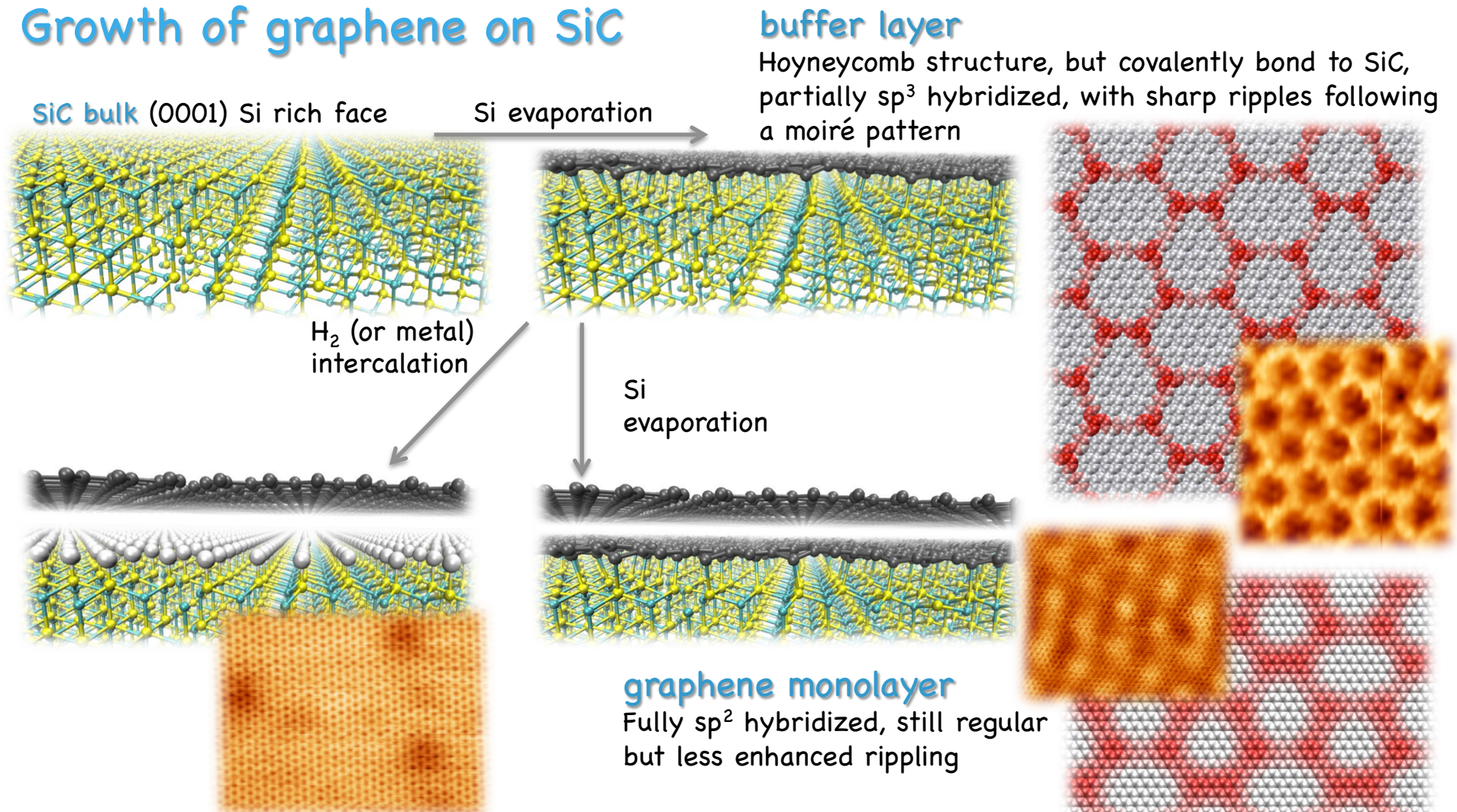
Conclusions on graphene for H-storage

- ✓ Graphene for H-storage requires its morphology manipulation to
 - Optimize the interaction with hydrogen
 - Build 3D systems
- ✓ Epitaxial graphene natural properties can be exploited to drive the nano-scale functionalization and design 3D frameworks



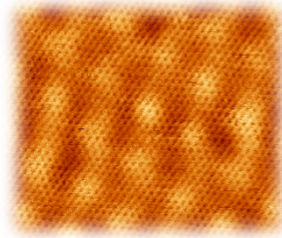
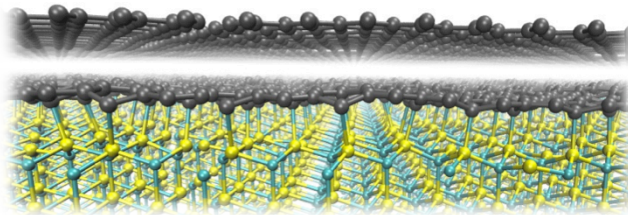
"Side results": Nano-electronics

Growth of graphene on SiC

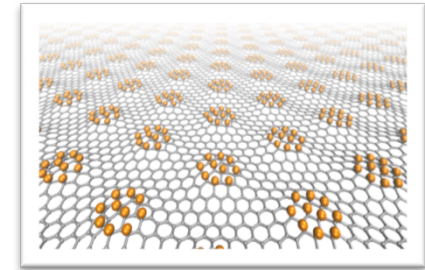
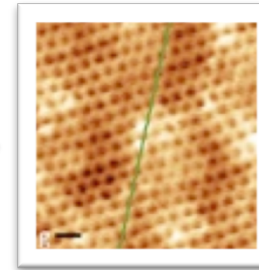


"Side results": Nano-electronics

graphene monolayer

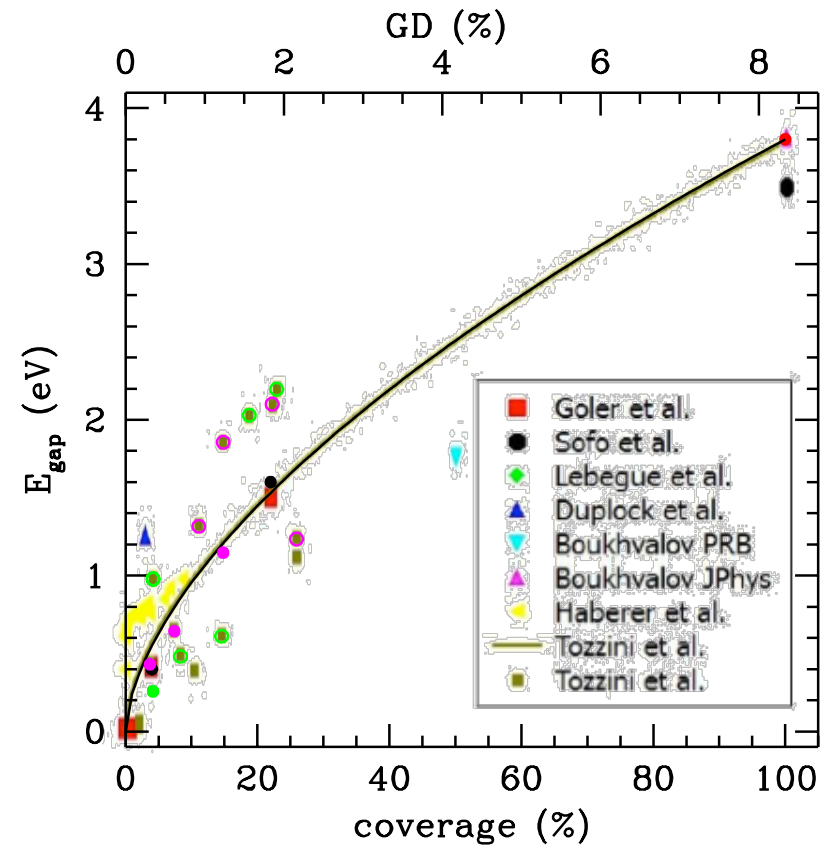


+H



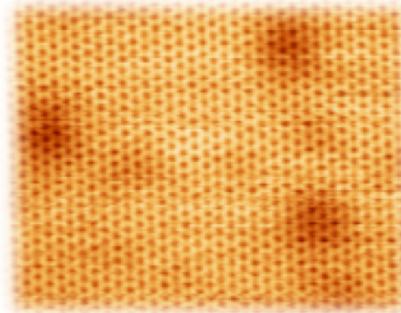
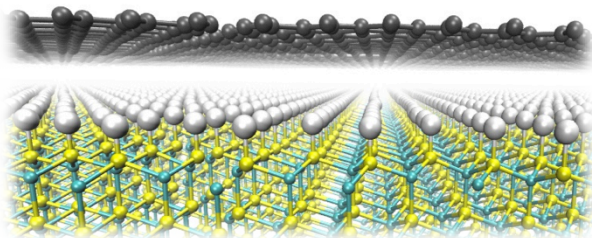
- ✓ A regular band gap increasing as a function of H coverage is found with DFT calculations
- ✓ The spread of data is due to different decoration
- ✓ This relationship could be used to measure the coverage by STS
- ✓ The band gap can be tuned by H decoration

Nano-Scale Corrugations in Graphene: A Density Functional Theory Study of Structure, Electronic Properties and Hydrogenation A Rossi, S Piccinin, V Pellegrini, S de Gironcoli, and Vtozzini JPCC, 2015

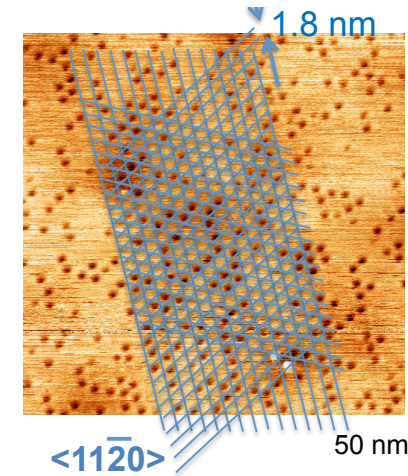


"Side results": Nano-electronics

quasi free standing graphene

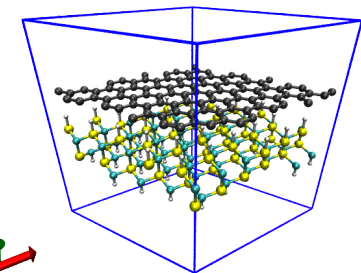


Zoom out



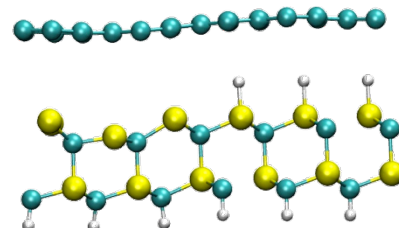
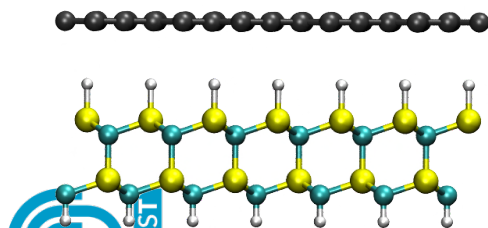
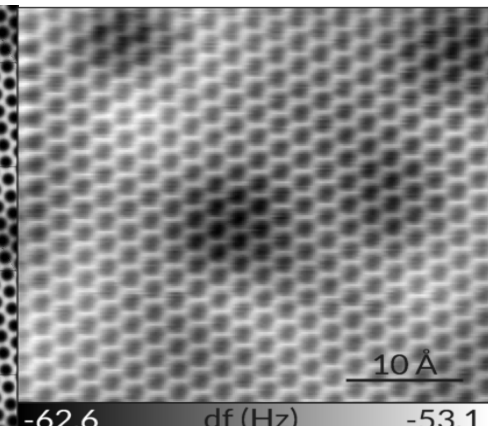
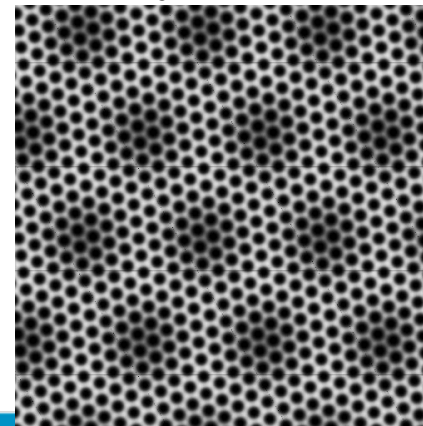
periodicity: 1.8 nm = SiC-6-

- ✓ The STM images show anomalies whose contrast depends on the voltage bias (Talk by Stefan Heun, 16th)
- ✓ Those anomalies follow a symmetry corresponding to the 6x6 with respect to SiC
- ✓ They were attributed therefore to vacancies in the H coverage
- ✓ DFT Calculations shows that vacancies of 3-7 H atoms can reproduce a deformation whose size and depth is comparable with experiment



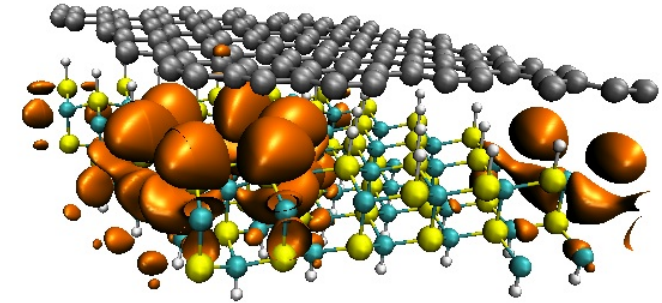
Theory

AFM measurement



"Side results": Nano-electronics

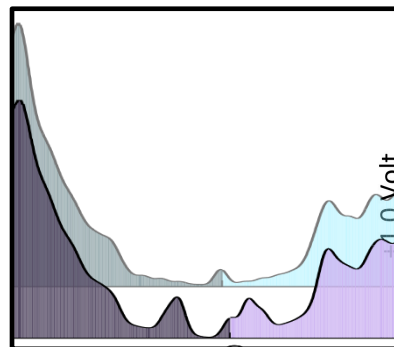
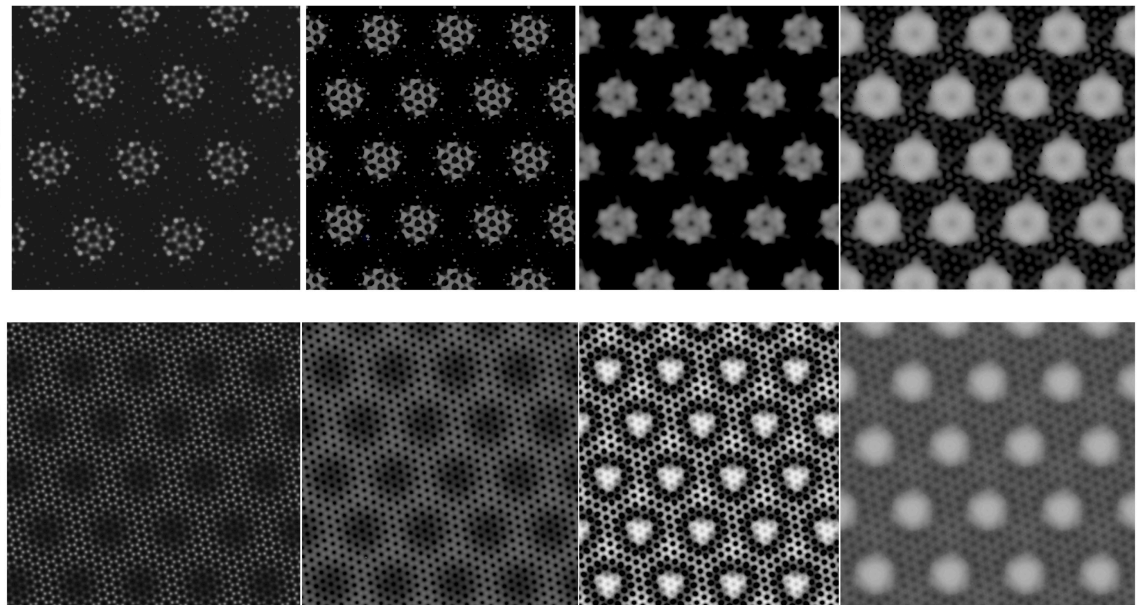
- ✓ The vacancies create localized electronic states responsible of the features in the STM contrast
- ✓ However the contrast can be either dark or bright, due to two opposite tendencies: the inward bending of graphene and the protruding capacity of the localized orbitals
- ✓ The size and energy of the states depend on
 - The doping or charge state of the sheet (substrate induced)
 - The voltage bias
 - The size and shape of the vacancy



⇒ The electronic properties can be tuned, since distribution, symmetry of vacancies depend on the conditions of H intercalation

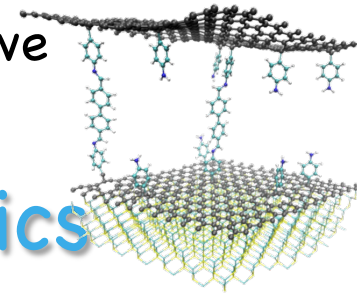
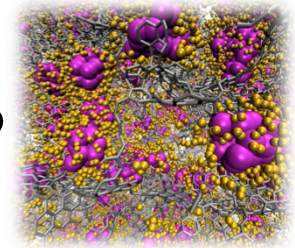
STM fixed height STM iso-charge

10⁻⁴ 10⁻⁵ 10⁻⁶



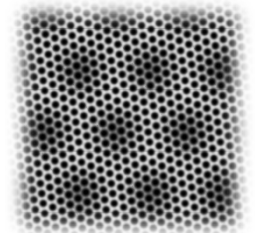
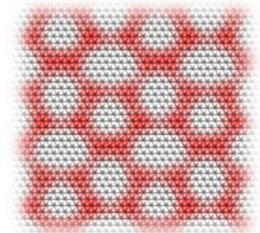
Conclusions: graphene for H-storage

- ✓ Graphene for H-storage requires its morphology manipulation to
 - Optimize the interaction with hydrogen
 - Build 3D systems from a 2D material
- ✓ Epitaxial graphene natural properties can be exploited to drive the nano-scale functionalization and design 3D frameworks



Conclusions: graphene for nanoelectronics

- ✓ Epitaxial graphene can assume different morphologies
 - Regular pattern of curvature (monolayer)
 - Concavities on a regular lattice, but with tunable size and densities (quasi free standing)
- ✓ Using these properties systems with different electronic properties can be obtained
 - Tunable band gap
 - Localized mid-gap states with different energies



Graphene must be manipulated to obtain different "graphenes" for different applications

Aknowlegements

Theory & Modeling

Tommaso Cavallucci
Luca Bellucci
Khatuna Kakhiani
Riccardo Farchioni
Vito Dario Camiola

PhD student Scuola Normale Superiore
Post-Doc NANO-Cnr Graphene Flagship
MCSA Fellow, NANO-Cnr
NANO-Cnr, Pisa
Post-Doc NANO-Cnr Graphene Flagship (Former)

Experiment

Stefan Heun
Yuya Murata
Torge Mashoff
Camilla Coletti
Vittorio Pellegrini

THANK YOU
FOR YOUR
ATTENTION

NANO-Cnr Pisa
NANO-Cnr Pisa
NANO-Cnr Pisa (former)
iit-CNI Pisa
Graphene labs Genoa

External Collaborators

Igor Baburin, Gotthard Seifert
Alexandr Talyzin
Silvia Giordani
Keisuke Takahashi, Shigehito Isobe, Kengo Omori

TU Dresden
Univ Umeå
iit NANO-Carbon Materials
Hokkaido University, Japan